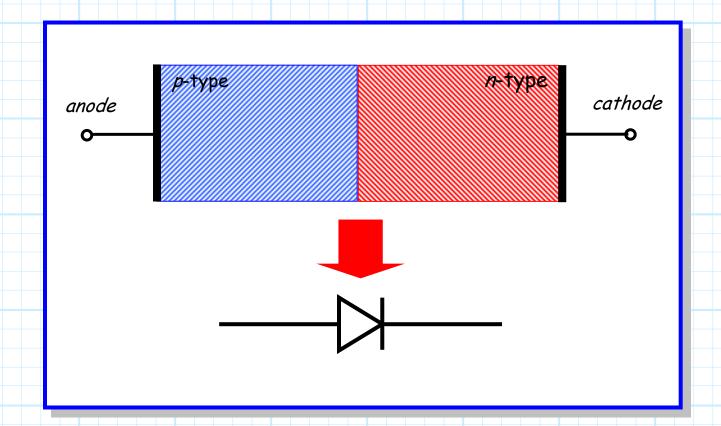
The p-n Junction Diode (Open Circuit)

We create a p-n junction diode simply by sticking together a hunk of p-type Silicon and a hunk of n-type Silicon!



Now, let's think about what happens here:

- 1) The concentration of holes in the anode is much greater than that of the cathode.
- 2) The concentration of free electrons in the cathode is much greater than that of the anode.

Diffusion is the result!

- 1) Holes begin to migrate across the junction from the anode to the cathode.
- 2) Free electrons begin to migrate across the junction from the cathode to the anode.

Q: Oh, I see! This is entropy at work. This diffusion will occur until the concentration of holes and free electrons become uniform throughout the diode, right?



A: Not so fast! There are more phenomena at work here than just diffusion!

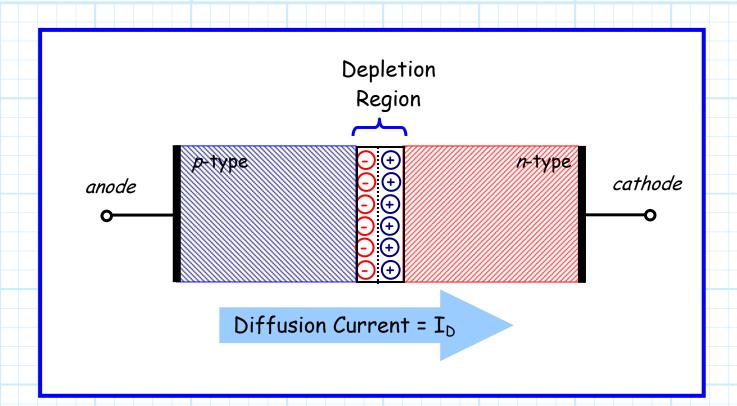
For instance, **think** about what happens when holes **leave** the *p*-type Silicon of the anode, and the free electrons **leave** the *n*-type Silicon of the cathode:



They uncover ions !!!

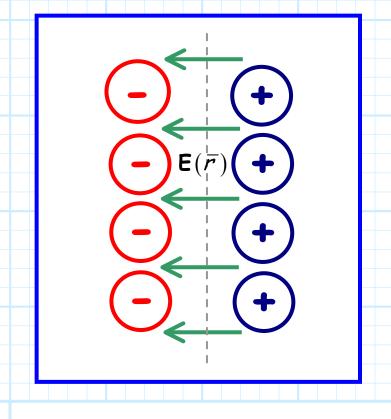
As a result, the charge density of the anode along the junction becomes negative, and the charge density of the cathode along the junction becomes positive.

This region of uncovered ions along the junction is known as the depletion region.



Now, something really interesting occurs.

The uncovered ions of opposite polarity generate an electric field across the junction!



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Recall that an electric field exerts a force on charge particles—charged particles like holes and free electrons!

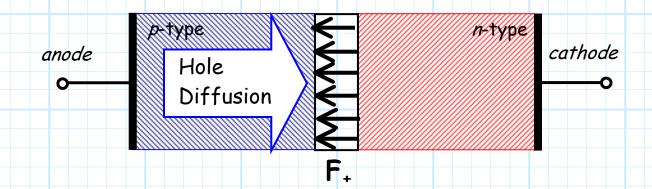
Let's see what this force is on both holes and free electrons:

For holes:

Using the Lorentz force equation, we find that the force vector \mathbf{F}_+ on a hole (with charge $Q_+ = -e$) located at position \overline{r} is:

$$\mathbf{F}_{\!\scriptscriptstyle{+}} = \mathbf{Q}_{\!\scriptscriptstyle{+}} \mathbf{E}(\bar{r})$$

Note that since the electric field vector in the depletion region is pointing from **right to left** (i.e., from the n-type Si cathode to the p-type Si cathode), and since the "charge" Q_{\star} of a hole is **positive**, the force vector likewise extends from **right to left**:



Look what happens! The electric field in the depletion region applies a **force** on the holes that is **opposite** of the direction of **hole diffusion**!

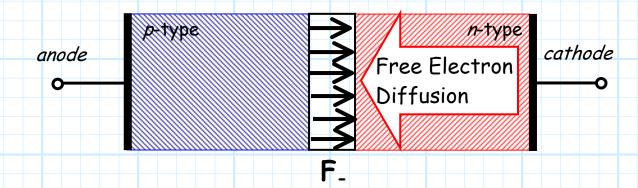
In other words, the electric field "holds back" the tide of holes attempting to diffuse into the *n*-type cathode region.

For free electrons:

Now, let's see what effect this electric field has on **free electrons**. Using the **Lorentz force equation**, we find that the **force** vector \mathbf{F} on a free electron (with charge $\mathbf{Q} = \mathbf{e}$) located at position \mathbf{r} is:

$$F = QE(\bar{r})$$

Note that since the electric field vector in the depletion region is pointing from **right to left** (i.e., from the *n*-type Si to the *p*-type Si), and since the charge Q_{-} of a free electron is **negative**, the force vector extents in the opposite direction of $\mathbf{E}(\bar{r})$ --from **left to right**:



Look what happens! The electric field in the depletion region likewise applies a force on the free electrons that is opposite of the direction of free electron diffusion!

In other words, the electric field "holds back" the tide of free electrons attempting to diffuse into the p-type anode region.



Q: So, does this electric field stop all diffusion across the junction? Is the diffusion current I_D therefore zero?

A: Typically NO! The electric field will greatly **reduce** the diffusion across the junction, but only in **certain** cases will it eliminate I_D entirely (more about **that** later!).

The **amount** of diffusion that occurs for a given electric field $\mathbf{E}(\bar{r})$ is dependent on how **energetic** the particles (holes and free-electrons) are!

Recall that these particles will have kinetic energy due to heat. If this energy is sufficiently large, a particle can still diffuse across the p-n junction!

To see why, consider the amount of energy E it would take to move a charged particle through this electric field. Recall from EECS 220 that this energy is:

$$E = -Q \int_{C} \mathbf{E}(\bar{r}) \cdot \overline{d\ell}$$

For our case, Q is the **charge** on a particle (hole or free electron), and **contour** C is a path that extends **across** the depletion region.

Moreover, we recall that this expression can be simplified by using electric potential, i.e.,

$$V = -\int_{C} \mathbf{E}(\bar{r}) \cdot \overline{d\ell}$$

Where V is the difference in **potential energy** (per coulomb) between a charge at either end of contour C. This of course tells us how much **work** must be done (per coulomb) to move a charge from **one end** of the contour to the **other**.

Of course V has units of **Volts**, but its more descriptive unit is **joules/coulomb**—energy per unit charge.

Therefore, the energy required to move a charge Q along some contour C can **likewise** be expressed as:

$$E = QV$$

Now, for our particular problem, the charge Q is either the charge of a **free electron** (Q_{+}) or the charge of a **hole** (Q_{-}) .

The **voltage** (i.e., potential difference) across the depletion region is called the **barrier voltage** V_B (sometimes denoted as V_O):

$$V_{\mathcal{B}} = -\int_{\mathcal{C}_{dr}} \mathbf{E}(\overline{r}) \cdot \overline{d\ell}$$

where the contour C_{dr} describes some path **across** the depletion region.

Typically, we find that when the junction diode is open circuited (i.e., v_D =0 and i_D =0), this barrier voltage is approximately—0.7 V!

Thus, we find that the **energy** required for a **hole** to **diffuse** across the depletion region is:

$$E_{R} = Q_{\perp} V_{R}$$

While the energy required for a free electron to diffuse across the depletion region is:

$$E_B = -Q_V_B$$

Note that both these energies are the same (positive) value!

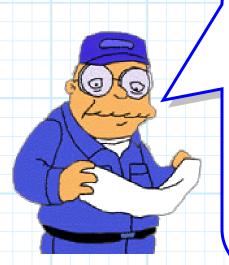
OK, here's the important part:

- A. If the particle has kinetic energy greater than E_B , it can diffuse across the depletion region.
- B. If the particle has kinetic energy less than E_B , then the electric field will "push" it back into either the ptype anode region (for holes) or the n-type cathode region (for free electrons).

Thus, the diffusion current I_D across the p-n junction will depend on three things:

- 1. The majority particle concentration. The more holes or free electrons there are, the more particles will diffuse across the junction.
- 2. The barrier voltage V_B . A lower barrier means more diffusion, a higher means less.

3. The diode temperature - Higher temperature means more kinetic energy and thus more diffusion. Lower temperature means less.



Q: Wait a minute! We've examined the behavior of holes in the p-type region and free electrons in the n-type region. These are the majority carriers for each of those Silicon types.

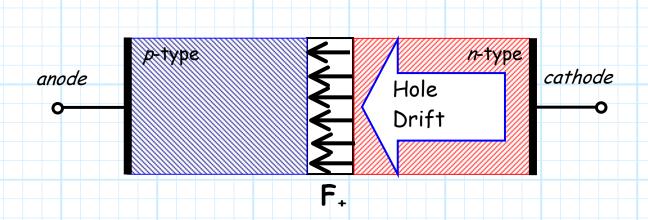
There are also minority carriers present in each side. What does the electric field in the depletion region do to them?

A: A great question! We will find that the electric field will have a profoundly different effect on minority carriers!

For holes:

Recall that the electric field in the depletion region applies a force on **positive** charges (holes) that is directed **from** the n-type (cathode) region **into** the p-type (anode) region.

This force of course **pushes** the holes in the *p*-type anode (the *majority* carriers) **back into** the *p*-type region. **However**, the same force will **pull** holes from the *n*-type region (the **minority** carriers) **into** the *p*-type region!



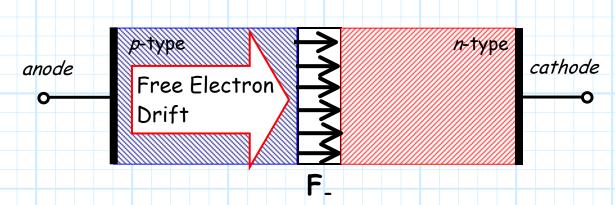
Any unsuspecting **minority** hole that "drifts" into the depletion region will from the *n*-type side will be **pulled** into the *p*-type side! Note that this result is **independent** of the kinetic energy of the particle—it takes **no** energy to "fall **downhill**".

This movement of charge is completely due to the force applied by the electric field—this is drift current I_s !

Now, for free electrons:

Recall also that the electric field in the depletion region applies a force on **negative** charges (free electrons) that is directed **from** the p-type (anode) region **into** the n-type (cathode) region.

This force of course **pushes** the free electrons in the *n*-type region (the **majority** carriers) **back into** the *n*-type region. **However**, the same force will **pull** free electrons from the *p*-type region (the **minority** carriers) into the *n*-type region!

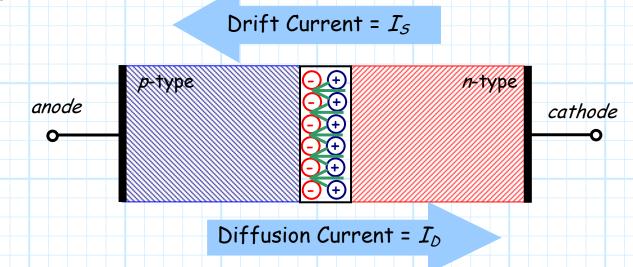


Any unsuspecting **minority** free electron that "drifts" into the depletion region will from the *p*-type side will be **pulled** into the *n*-type side! Note that this result is **independent** of the kinetic energy of the particle—it takes **no** energy to "fall **downhill**".

This movement of charge is completely due to the force applied by the electric field—this is also drift current $I_{\mathcal{S}}$!

There are two very important differences between drift and diffusion currents in a p-n junction diode:

1. Drift and Diffusion current flow in opposite directions – The Diffusion current I_D flows across the p-n junction from anode to cathode, while Drift current I_S flows across the p-n junction from cathode to anode.



2. Diffusion current depends on the barrier voltage V_B , but Drift Current does not. - As the barrier voltage increases, fewer and fewer of the majority carriers will have sufficient kinetic energy to cross the depletion region—the diffusion current will decrease.

Conversely, minority carriers require **no energy** to be swept across the depletion region by the electric field, the value of the **barrier voltage** is irrelevant to the value of I_S .

Now, for an open-circuited (i.e., **disconnected**) junction diode, the **total current** through the device **must be zero**. In other words, the diffusion current I_D must be **equal but opposite** that of the drift current I_S , such that:

$$I_D - I_S = 0$$

This is the **equilibrium** state of a **disconnected** junction diode. We find that typically this drift/diffusion current is **very** small, generally 10⁻⁸ to 10⁻¹² Amps!

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